

Interface Structure Regulation of Ag Lithiophilic Layer towards Uniform Lithium Nucleation/Growth

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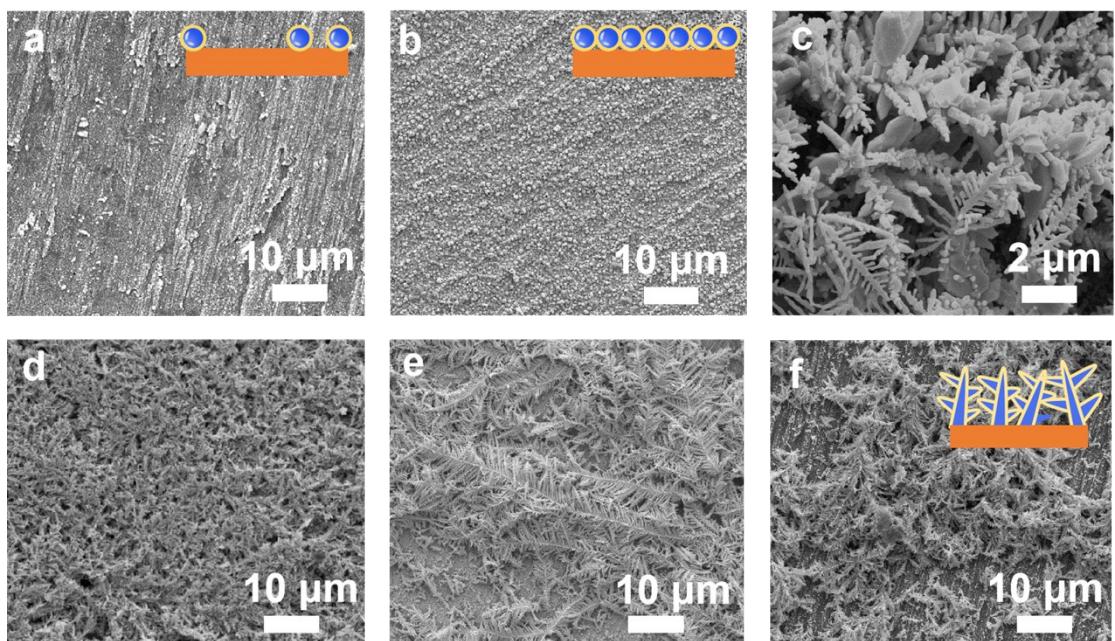


Figure. S1 SEM images of different reaction concentration of AgNO_3 solution. (a) 1 mM L^{-1} AgNO_3 . (b) 5 mM L^{-1} AgNO_3 . (c) 30 mM L^{-1} AgNO_3 . (d) 60 mM L^{-1} AgNO_3 . (e) 100 mM L^{-1} AgNO_3 . (f) 200 mM L^{-1} AgNO_3 .

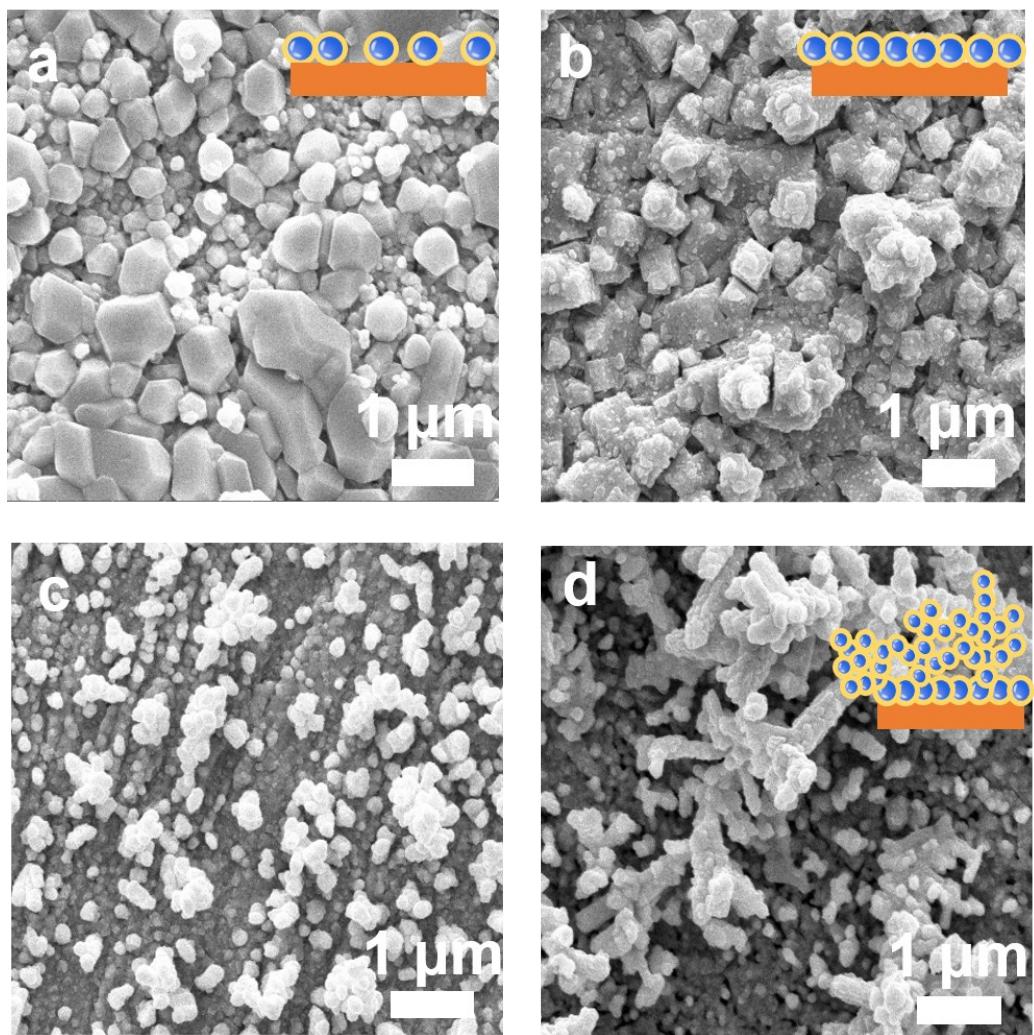


Figure. S2 SEM images of different reaction time of 5 mM L⁻¹ AgNO₃ solution. (a) 1 min. (b) 3 min. (c) 5 min. (d) 10 min.

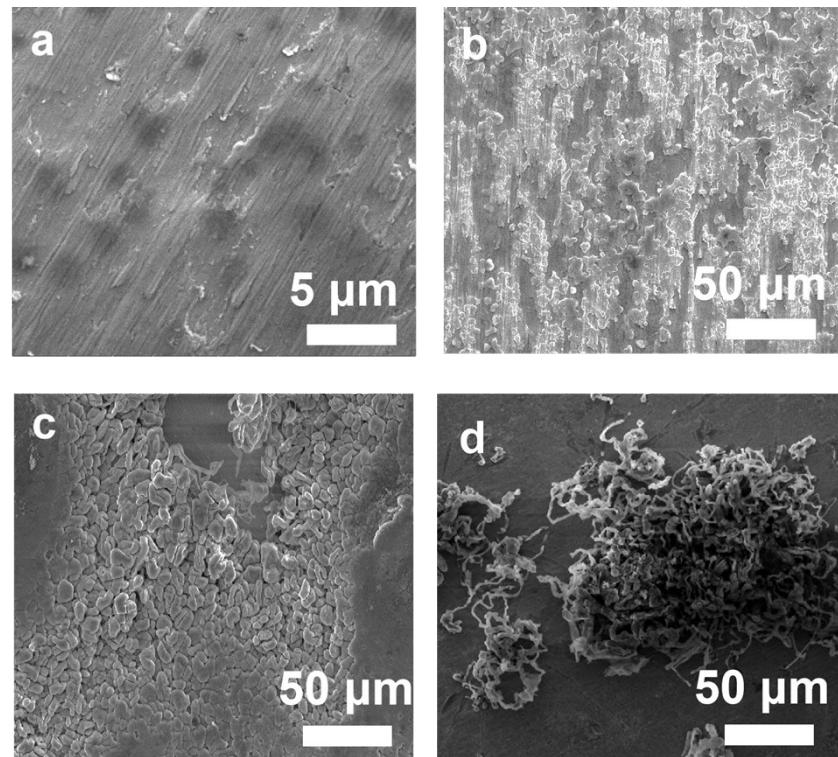


Figure. S3 Morphological evolution during the Li plating and stripping on Cu foil current collector. SEM images of the Cu foil after been plated a capacity of (a) 0 mAh cm⁻², (b) 0.5 mAh cm⁻², (c) 2 mAh cm⁻², (d) then been stripped to 0.5 V.

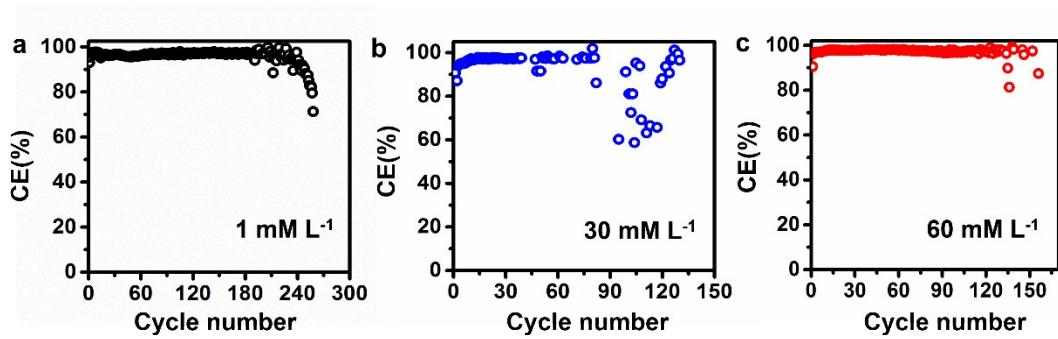


Figure. S4 CEs of different reaction concentration of AgNO_3 solution. (a) 1 mM L^{-1} AgNO_3 . (b) 30 mM L^{-1} AgNO_3 . (c) 60 mM L^{-1} AgNO_3 .

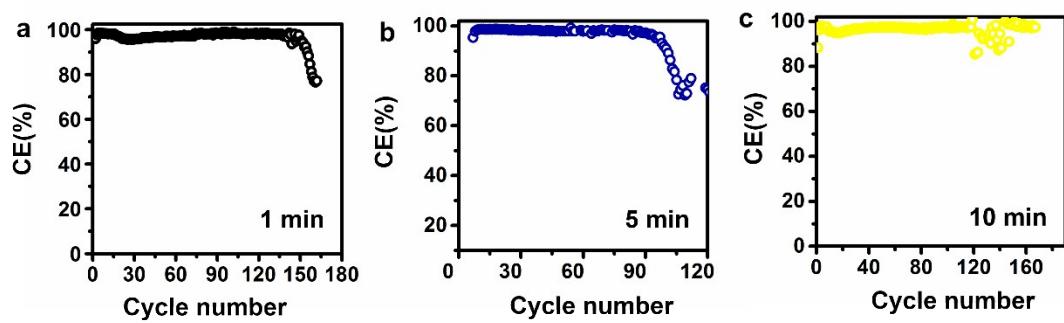


Figure. S5 CEs of different reaction time of 0.5 mM L^{-1} AgNO_3 solution. (a) 1 min. (b) 5 min. (c) 10 min.

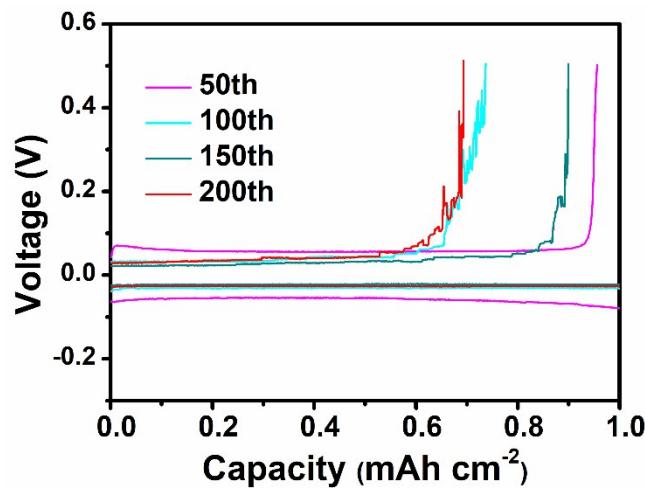


Figure. S6 Voltage profiles of the Cu foil at different cycles at 1 mA cm⁻² for a total of 1 mAh cm⁻² of Li.

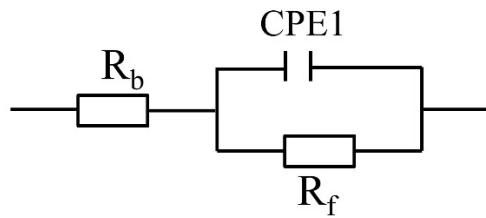


Figure. S7 Equivalent circuit diagram for EIS plots.

Table S1. Electrochemical impedance fitted parameters for in Figure. 4 (c-d). with an equivalent circuit model shown in Figure S6

	Cu foil		Ag-Cu	
	$R_b(\Omega)$	$R_f(\Omega)$	$R_b(\Omega)$	$R_f(\Omega)$
5 cycles	2.831	326	2.535	107.3
20 cycles	2.896	310	3.442	36.18
50 cycles	3.131	81.73	4.333	37.15
100 cycles	3.046	49.66	3.482	38.64

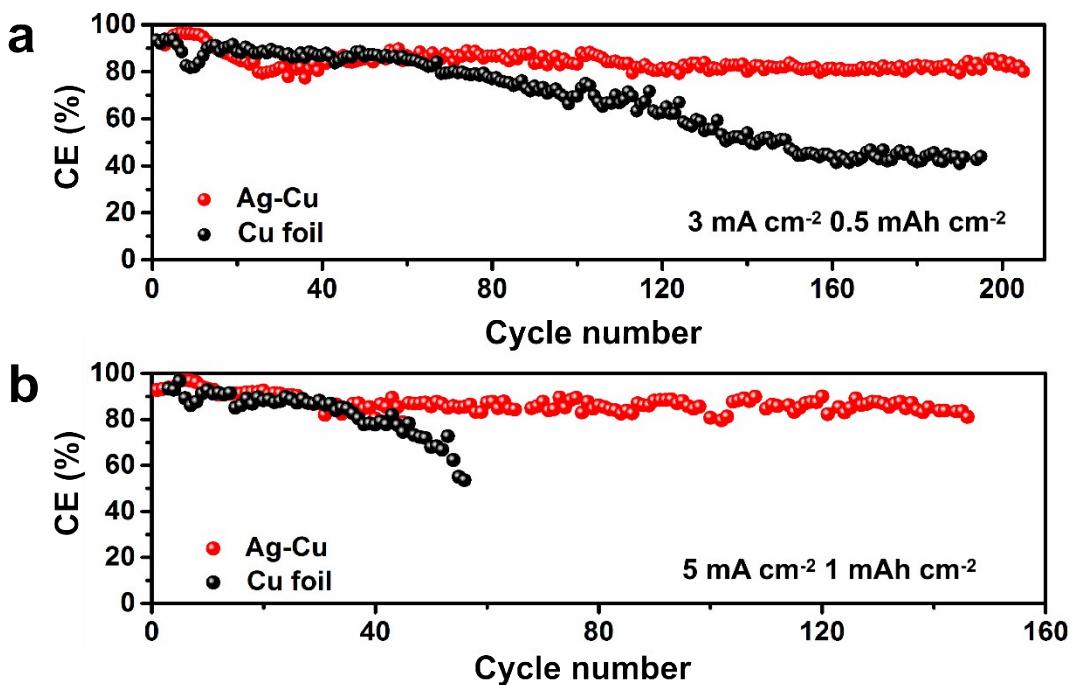


Figure. S8 CEs of the Cu foil, Ag-Cu electrodes at current density of 3 mA cm^{-2} and 5 mA cm^{-2} . (a) 0.5 mAh cm^{-2} . (b) 1.0 mAh cm^{-2} .

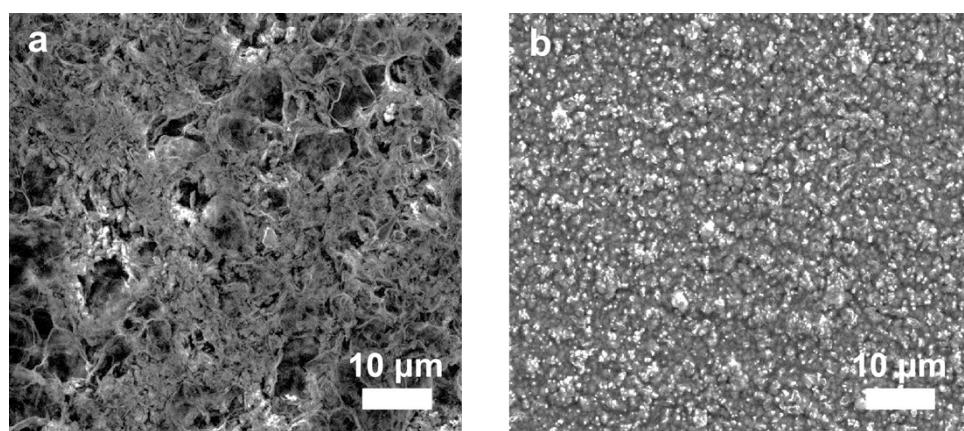


Figure. S9 SEM images of the Cu foil and Ag-Cu samples after cycles at 1 mA cm^{-2} with a total 1 mA cm^{-2} of Li. (a) Cu foil. (b) Ag-Cu foil.

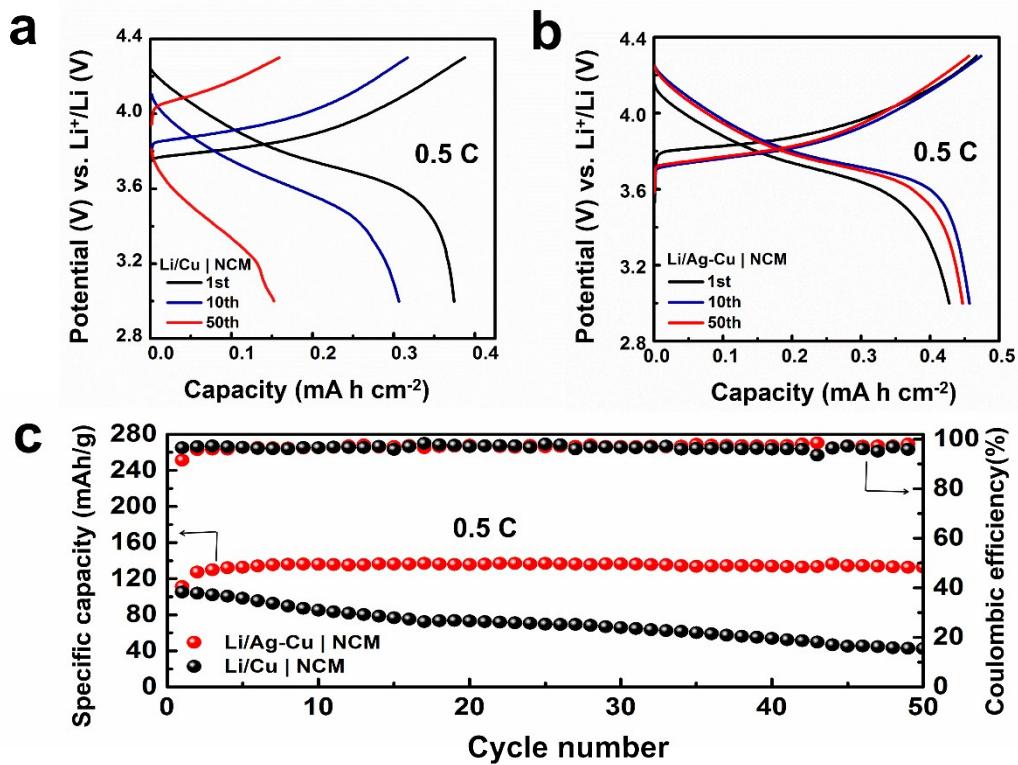


Figure S10. Voltage profiles of (a) the Li/Cu|NCM cell and (b) the Li/Ag-Cu|NCM cell. (c) Cycling performance of Li/Cu|NCM and Li/Ag-Cu|NCM cells at 0.5 C.

Tables S2 Summary of electrochemical performance of Li plating/stripping on Cu-based current collectors.

Modified	Substrate	Reaction condition	Reaction time	Current density & Capacity	Cycles	CE	Reference
Sintering at							
3D Cu-Zn alloy	Cu-Zn particles	600°C and Ar/H ₂ reduction	240min	1 mAh cm ⁻² at 1 mA cm ⁻²	160	98.3%	1
Porous copper	Cu foam	Template and electro-deposition	300min	1 mAh cm ⁻² at 1 mA cm ⁻²	270	98%	2
Graphene anchored	Cu foam	Physic asorption	1min	1 mAh cm ⁻² at 1 mA cm ⁻²	200	About 98%	3
3D porous Cu	Cu-Zn alloy	Electrochemical etching		1 mAh cm ⁻² at 1 mA cm ⁻²	200	97.9%	4
3D structured	Cu foil	Electro-deposition	20min	1 mAh cm ⁻² at 0.5 mA cm ⁻²	80	95%	5
3D Li ₂ O filled nano-cluster	Cu foil	hydrothermal reaction and Ar/H ₂ reduction	960 min		150	96.7%	6
CNF and Cu particles	Cu foil	Electrospinning and sintering	480min	1 mAh cm ⁻² at 1 mA cm ⁻²	400	96%	7
3D ordered macro-porous	Cu foil	Template	120min	0.5 mAh cm ⁻² at 0.5 mA cm ⁻²	80	93.1%	8
CuO Nanosheets	Cu foil	Wet chemical reaction into NH ₄ OH solution	480min	1 mAh cm ⁻² at 1 mA cm ⁻²	180	94%	9
Ag particles	Cu foil	Electroless plating	1.5min	1 mAh cm ⁻² at 1 mA cm ⁻²	100	88%	10
Ag nanopartic les	Cu foil	In-Situ replacement reaction, 5 mM L ⁻¹ AgNO ₃	3min	1 mAh cm ⁻² at 1 mA cm ⁻²	400	97.56 %	This work

Reference:

1. H. Fan, Q. Dong, C. Gao, B. Hong and Y. Lai, *Materials Letters*, 2019, **234**, 69-73.
2. X. Ke, Y. Cheng, J. Liu, L. Liu, N. Wang, J. Liu, C. Zhi, Z. Shi and Z. Guo, *ACS Appl Mater Interfaces*, 2018, **10**, 13552-13561.
3. G. Yang, J. Chen, P. Xiao, P. O. Agboola, I. Shakir and Y. Xu, *Journal of Materials Chemistry A*, 2018, **6**, 9899-9905.
4. H. Zhao, D. Lei, Y.-B. He, Y. Yuan, Q. Yun, B. Ni, W. Lv, B. Li, Q.-H. Yang, F. Kang and J. Lu, *Adv. Energy Mater.*, 2018, **8**.
5. X. Ma, Z. Liu and H. Chen, *Nano Energy*, 2019, **59**, 500-507.
6. Z. Zhang, X. Xu, S. Wang, Z. Peng, M. Liu, J. Zhou, C. Shen and D. Wang, *ACS Appl. Mater Interfaces*, 2016, **8**, 26801-26808.
7. W. Jia, T. Chen, Y. Wang, S. Qu, Z. Yao, Y. Liu, Y. Yin, W. Zou, F. Zhou and J. Li, *Electrochimica Acta*, 2019, **309**, 460-468.
8. Y. Tang, K. Shen, Z. Lv, X. Xu, G. Hou, H. Cao, L. Wu, G. Zheng and Y. Deng, *J. Power Sources*, 2018, **403**, 82-89.
9. C. Zhang, W. Lv, G. Zhou, Z. Huang, Y. Zhang, R. Lyu, H. Wu, Y. Qinbai, F. Kang and C. Yuan. *Adv. Energy Mater.*, 2018, **21**, 1703404.
10. Z. Hou, Y. Yu, W. Wang, X. Zhao, Q. Di, Q. Chen, W. Chen, Y. Liu and Z. Quan, *ACS Appl. Mater Interfaces*, 2019, **11**, 8148-8154.